Docket No.: 1999P2416

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant

MANFRED FRANK ET AL.

Filed

CONCURRENTLY HEREWITH

Title

SCRATCH-RESISTANT COATING FOR SEMICONDUCTOR

COMPONENT

INFORMATION DISCLOSURE STATEMENT

Hon. Commissioner of Patents and Trademarks, Washington, D.C. 20231

Sir:

In accordance with 37 C.F.R. 1.98 copies of the following patents and/or publications are submitted herewith:

U.S. Patent 5,479,049 (Aoki et al.), dated December 26, 1995;

European Patent Application 0 152 744 A1 (Arndt et al.), dated August 28, 1985;

European Patent Application EP 0 791 899 A2 (Setlak), dated August 27, 1997;

European Patent Application EP 0 915 373 A1 (Yau et al.), dated May 12, 1999;

Patent Abstracts of Japan 11 135 691 A (Ryoji et al.), dated May 21, 1999;

International Search Report, dated August 2, 1999.

Respectfully submitted,

For Applicants

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Date: February 4, 2002

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INFORMATION DISCLOSURE STATEMENT BY APPLICANT (37 CFR 1.98(b))				Applicant MANFRED FRANK ET AL.				
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	L	0 915 373 A1	5/12/99	Europe	 			
	М	11 135 691 A	5/21/99	Japan	 			
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OTHER	l	UMENTS (Inclu	ding Autl	hor, Title, Date, F	Pertinent	Pages, e	etc.)	
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